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DATE MAILED: 08/11/2005

APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/044,864		10/22/2001	Vladimir Zubkov	01-569/LSI1P177	9835
24319	7590	08/11/2005		EXAMINER	
LSI LOGIC			ERDEM, FAZLI		
1621 BARBER LANE MS: D-106				ART UNIT	PAPER NUMBER
MILPITAS,	CA 950	35	2826		

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)				
	Office Action 0	10/044,864	ZUBKOV ET AL.				
	Office Action Summary	Examiner	Art Unit				
		Fazli Erdem	2826				
Period f	The MAILING DATE of this communication apor Reply	pears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
1)🔯	Responsive to communication(s) filed on 06 I	May 2005.					
· —		s action is non-final.					
3)	·						
Disposit	ion of Claims						
5)🖂	•						
Applicat	ion Papers						
9)□	The specification is objected to by the Examin	er.					
10)	0) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.						
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11)	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority (ınder 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.							
Attachmen	t(s)						
	e of References Cited (PTO-892)	4) Interview Summary	(PTO-413)				
3) 🔯 Inforr	e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) r No(s)/Mail Date <u>05/06/2005</u> .	Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:	te atent Application (PTO-152)				

Art Unit: 2826

DETAILED ACTION

Allowable Subject Matter

1. Claims 1-3, 5-8 and 10-13 allowed.

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 15-17 rejected under 35 U.S.C. 103(a) as being unpatentable over Besser et al. (6,633,085) in view of Lopatin et al. (6,703,307).

Regarding Claims 15-17, Besser et al. disclose a method of selectively alloying interconnect regions by ion implantation where in Fig. 6, surface of silicon oxide layer 34 is implanted/doped by dopants 42 thereby forming a barrier layer, extending from within the silicon dioxide layer to the surface of the silicon oxide layer 34. Claim 9 of Besser et al. disclose that the dopants could be one of Calcium, which is a divalent ion.

Furthermore, consequently, a conductive plug layer 48 is deposited on the surface of the barrier layer, preventing diffusion of copper into the substrate. Following the copper fill process an anneal process is performed. Besser et al. fail to disclose the required multipl silicon dioxide layers. However, Lopatin et al. disclose a method of impoanting after copper seed deposition where in Fig. 3, multiple silicon dioxide layers are disclosed.

Application/Control Number: 10/044,864

Art Unit: 2826

It would have been obvious to one of having ordinary skill in the art at the time

Page 3

the invention was made to include the required multiple silicon oxide layers in Besser et

al. as taught by Lopatin et al. in order to have a multi-layer semiconductor device.

Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Fazli Erdem whose telephone number is (571) 272-1914. The

examiner can normally be reached on M - F 8:00 - 5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Nathan Flynn can be reached on (571) 272-1915. The fax phone number for the

organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

FE

August 8, 2005

NATHAN J. FLYNN

SUPERVISORY PATENT EXAMINED

TECHNOLOGY CENTER ?